March. 14, 2013 Wolfgang SCHEIDLER Rue des Drapiers 17-23 B-1050 Brussels





EDA CapTech IAP1 presentation to ESA ESCCON 2013

Institutional Setting



EDA Mission:

The European Defence Agency supports the Council and the Member States in their effort to improve the EU's defence capabilities in the field of crisis management and to sustain the CSDP as it stands now and develops in the future

Council Joint Action





- EU Agency located in Brussels
- Under the Council's Authority
- Building Capabilities
- Enhancing Armaments Cooperation
- Promoting Research & Technology
- Strengthening the Defence Industrial & Technological Base (DTIB)
- Close interaction with the Member States







EDA R&T CAPTECHS



EDA R&T Programmes - Funding & Contracting Schemes

- → Through individual ad hoc projects (Cat-B projects)
 - Depend on pMS and industry interests
 - Project size typically up to a few million €, duration 3 years
- Through EDA's operational budget
 - only small budget available, requires support from member states
 - selected studies e.g. for technology roadmap and forcasts, technology market research and startegic research strategies with a duration of less than 12 month

Through Joint Investment programms

- JIP Force Protection (finished)
- JIP ICET (Innovative Concept on Emerging Technology) (final phase)
- JIP CBRN (chemical, biological, radiological and nuclear protection) (beginning phase)
- JIP UAS (in preparation)
- JIP ICET II (in preparation)
- coordinated and supported by pMS
- industry/research community bottom up innovative idea approach





IAP01 Components

- Strategic Research Agenda
- EDA taxonomy

GENC

Based on EDA IAP1 DISCOTECH study as of 2009/10



Micro and Nano Electronics/Optronics in

- Optic Photonics; Opto Electronics
- RF microWaves
- Digital Processing
- Power Supply & Energy Management
- Mixed Signal incl. AD/DA
- Sensors and Smart Actuators
- Transversal (OPOE & Electronic Components)

Example:

Mixed Signal Analogue & Digital inclusive Conversion AD / DA,

Identifies technologies where Europe, with appropriate support, can achieve world leadership.



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Operating EDA Captech IAP1: way of working

Management/Coordination : 3 meetings per year – 1.5 day

One (or more) Workshop(s) per year

- Review of one technical/technological domain (system needs, state of the art, challenges for military applications and possible Eol)
- A long history of Workshops: Opto/mW (Rome, 2002), Nanotechnologies (Paris, 2002), mW/RF disruptive/ large gap (Göteborg, 2003), Thermal management (Orsay, 2004), Signal Processing (Brussels, 2005, 180 attendees), Components for Homeland Security (Paris, 2006, 150 attendees), Power Supply and Energy Management (Brussels, 2007), Photonics (London October 2007), Discotech (Paris September 2008 110 attendees), Nanotechnology (Brussels, May 2012), PCB SRA (Brussels, (18 Oct. 2012),...
- Future Work shops: PCB SRA (Brussels, May./Oct. 2013, Super Conductivity (May 2013), Energy Sources (Oct 2013), Printed Circuit Board (Oct. 2013), Meta Material (antenna & microwave applications (2014, t.b.d.):



Shared vision and prioritization

A long history at Captech IAP1 with cooperative activities



new proposals to be prepared !



www.eda.europa.eu

Recently Finished Programms

CapTech IAP 1

→ finished Cat. B projects

AGENCY



Project	cMS	Technology	Ends	In∨t in M€
ARChitechture for Advanced Modulation in Optoelectronic RF oscillators & RF Systems	FR, IT	Tunable laser components; demonstrate processing functions based on dual frequency laser beams	2011	5,1
CODFISH Critical Optical Devices for Future Integrated Sampling Architectures	UK, IT	Optoelectronic critical components; advancement of high-performance optical components; high speed optical sampling applications (≥4 Gsamples/s, over instantaneous bandwidths of typically 18GHz.	2012	2,5
MINERVE Identification and Health Monitoring of Equipement in Real Life	IT, FR, NL	Automatic health monitoring; <i>implement a cost</i> <i>effective solution for real-time, continuous</i> <i>identification and life status monitoring of military</i> <i>equipments and weapon systems.</i>	2012	6,7
SWAP Switched Applications	SE, NL	Enabling technologies for active electronically scanned arrays; <i>local power generation and amplification based on switched technologies. The focus is on cost and performance.</i>	2012	4.4
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Running Programms

CapTech IAP 1

running Cat. B projects



Project	cMS	Technology	Ends	Invest in M€
MANGA Manufacturing GaN	DE, FR, IT, SE, UK	SiC waifer manufacturing & GaN epitaxy	2013/14	16
EDA Soc EDA System on Chip Plattform	FR, IT, DE, NO	System on the Chip - design & applications	2014	22
THIMS Technology for High Speed Mixed Signal Circiuts	FR, DE	High Speed Mixed Signal Circuits	2014	4,8
MAGNUS GaN with UMS GH25 process	FR, DE, UK, SE, NL	Application technologies for GaN on SiC, based on UMS GH25 process	2015	12





Projects in preparation

- CapTech IAP 1
- Cat B projects in preparation for OD, PA and/or contract
- → Final industry proposal



Project	cMS	Technology	Invest <i>M</i> €	Contract expected
PERU PACKAGING 3D FOR HETEROGENEOUS RUGGED	FR , NO	Advanced 3D Packaging for Rough Military Applications	~3,9	2013
TIPPSI THz Imaging Phenomenology Platforms for Stand-off IED detection	DE , SE, NL, PO	THz Imaging Phenomenology Platforms for Stand-off IED detection (TIPPSI)	2,1	2013
PRECISE Prediction on Reliability for Electronics Components: Implementation in Standards in Europe	FR, DE	Prediction of Reliability for Electronics Components: Implementation of Stds Europe	t.b.c.	2013
HIPPOMOS High Performances comPact Optoelectronic Microwave OScillators	FR, IT	High Performances compact Opto- electronic Microwave Oscillators	t.b.c	2013

→ various EOIs in preparation



JIP ICET Projects

→ JIP ICET projects



Project	Industry/ Academi a from pMS	Lead	Technology	Ends
METAFORE	ES, DE, FR,	Tafco Metawire less	Forecasts in Metamaterials with Extreme Parameters for Disruptive Antennas, Radomes, and Cloaking in Radar Applications; European technology roadmap	12.2011
METALESA	ES, IT , DE, FR	Tafco Metawire less	Metamaterials & component design for Active Electronically Scanned Arrays; analysis , simulation, design	04.2013
SARape	DE, PL, HU, CY	FHG FHR	Synthetic Aperture Radar for all weather penetrating UAV applications,; 94 GHz SAR Radar, on board processing, data link and signal processing; successfully developed demonstrator	02.2013
NANOCAP	SP, IT, FR, CY	DAS	Novel NANO structured optical C omponents for CBRN detection and high perform A nce o P to- microwave links;	11.2012



Operational Budget studies



Project	Industry Academia from pMS	Lead	Technology	End
EDTID	SE, UK, FR,	FOI	European Defence Technology and Industrial Dependencies; identification of key enabling and critical technologies and supply chains; case studies for UAS and helicopter systems	2012
PCB	FR, UK, IT, NL SE, DE	MBDA	Printed Circuit Boards for Military Applications; European technology roadmap	2013
"Non EU Dependen cies study" (EDA lead I&M !)	NL, UK, FR, IT	TNO	"Investing in Key Unmanned System Technologies and Capabilities"; Investigation on critical payload electronics & optronics for future UAS respectively RPAS (kick off: Jan. 2013)	2014
SRA CDTComp)	t.b.d.	t.b.d.	Strategic Research Agenda on Critical Defence Technologies for Components (in preparation, II Q 2013!)	2014 t.b.d.





Key Initiatives & Activities Supporting Cross Domain Synergies

- ESA EDA Administrative Arrangement
- European Framework Cooperation

"EDA, EC and ESA aim at maximising complementary and synergy of civilian security, space and defence related R&T activities



ESA & EDA signed on 20 June 2011, Le Bourget

Critical Space Technology for European non-Dependence

- → contribution to 2nd Mapping Process; Urgent Action List 2012/13
- → relevant running EDA Projects referenced
- → contribution to 3rd Mapping Process: in preparation & to be conducted in 2013
- ETnD ASD Dual Use document: major contributions from CapTech IAP1 addressing key enabling (KET) & nano technologies in context to potential H2020
- EDA IAP1 and ESA info exchange:
 - Wide Band Gab Semiconductor work shop, Sept. 2012
 - EDA-ESA SoC work shop, Feb. 2013
 - PCB

ETnD: EDA work strand









